

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	994	(sulfuric sulphuric)adj acid with peroxide same nitric adj acid and (resin polymer copolymer)	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 07:33
2	BRS	L2	412	1 and (semiconductor photoresist)	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 07:33
3	BRS	L3	900	(sulfuric sulphuric)adj acid with peroxide with nitric adj acid and (resin polymer copolymer)	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 13:06
4	BRS	L4	361	3 and (semiconductor photoresist)	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 13:16

	Type	L #	Hits	Search Text	DBs	Time Stamp
5	BRS	L5	126	4 and (reuse reusing recycle recycling recycled treat treatment treating purify purification) with (sulfuric sulphuric)	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 09:30
6	BRS	L6	12	INAGAKI-Y\$.in. and (sulfuric sulphuric)adj acid with peroxide same nitric adj acid	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 13:35
7	IS&R	L7	2	("6724638").PN.	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 09:33
8	BRS	L8	779	(sulfuric sulphuric)adj acid with (peroxide ozone peroxo)same nitric adj acid and (semiconductor photoresist)	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 09:55

	Type	L #	Hits	Search Text	DBs	Time Stamp
9	IS&R	L9	4910	((525/344,345,346) or (210/749) or (423/531) or (521/33)).CCLS.	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 09:55
10	BRS	L10	18	(sulfuric sulphuric)adj acid with (peroxide ozone peroxo)same nitric adj acid and 9	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 09:56
11	BRS	L11	16	10 not 5	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 09:57

	Type	L #	Hits	Search Text	DBs	Time Stamp
29	BRS	L30	14	INAGAKI-Yasuhito\$.in. and (sulfuric sulphuric)adj acid and peroxide and nitric adj acid	US- PGPUB; USPAT; USOCR; EPO; JPO; DERWEN T	2005/06/07 13:45